Research Article

P3HT:PCBM Incorporated with Silicon Nanoparticles as Photoactive Layer in Efficient Organic Photovoltaic Devices

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Silicon nanoparticles doped poly(3-hexylthiophene) and [6,6]-phenyl C61-butyric acid methyl ester blends (P3HT:PCBM: Si NP) have been produced as the photoactive layer of organic photovoltaic devices (OPVs). The silicon nanoparticles’ size is between 80 and 100 nm checked by transmission electron microscope (TEM). The 0.35 wt% Si NP doping OPVs exhibit higher power conversion efficiency (PCE) than other OPVs. The PCE of the OPVs increases from 3.01% to 3.38% mainly due to increasing short-circuit current density from 8.38 to 9.48 mA/cm², while the open-circuit voltage remains the same. The Si NP can provide extra exciton separation and electron pathways in hybridsolar cells.

1. Introduction

Solar energy has been greatly cared as a renewable energy source. Organic photovoltaic devices are attractive low-cost alternative compared with thin-film solar cells (single-poly-crystalline and amorphous thin films) and compound-based solar cells (copper indium gallium (di)selenide (CIGS), GaAs, CdTe). They are easily produced and large-area modules can be made with roll-to-roll process.

The PCE of OPVs with poly(3-hexylthiophene) (P3HT) and [6,6]-phenyl C61-butyric acid methyl ester (PCBM) blend as the photoactive layer is high compared with that of other OPVs so far. The P3HT provides the pi-orbit electron excitation during the photovoltaic process [1]. The PCBM usually acts an electron transport material in polymer solar cells.

The PCE of OPVs under AM 1.5 conditions has exceeded 7.4% [2]. The PCE of OPVs can be improved by doping nanomaterials like single-walled carbon nanotubes [3], multiwalled carbon nanotubes [4], nanodiamond [5], Fe₃O₄ magnetic nanoparticles [6], and ZnO nanorods [7]. Nanomaterials, which can be used to make superstrong metals [8], have become popular as semiconductor nanocrystals and solar cell materials due to their high surface to volume ratio, quantum confinement [9], quantum size [10], and small size effect [5].

Silicon, which has been successfully applied in solar cell and microelectronics industry, is a potential candidate for polymer-nanomaterials solar cells owing to its abundance, nontoxicity, and strong ultraviolet absorption. Doping Si NP into polymer materials acting as the photoactive layer of OPVs may increase the electron collection rate in the mixture. This work investigates the effect of employing P3HT:PCBM:Si NP as photoactive layer in OPVs on their electrical and optical properties.

2. Experimental Procedure

Organic photovoltaic devices were fabricated on indium tin oxide (ITO) coated glass substrates. The ITO glass substrate was ultrasonic cleaned in acetone, isopropanol, and deionized water in sequence to remove contaminants, then dried by nitrogen. After that, the ITO glass substrates were oxygen plasma cleaned by an inductively coupled plasma system to make the ITO surface hydrophilic. A 40-nm-thick layer of poly(3,4-ethylenedioxythiophene) polystyrenesulfonate) (PEDOT:PSS, Baytron P 4083) was spin-coated onto the ITO
glass substrate with 2600 rpm spin speed and then baked at 120°C for 30 minutes.

The photoactive layer was made of P3HT:PCBM:Si NP dissolved in 1,2-dichlorobenzene. The P3HT (FEM. Inc.) and PCBM (Nano-C) were 10:8 wt% in proportion. The Si NP (ITRI Taiwan) of size 80–100 nm prepared by the vibrating milled solid-state reaction was used. Various concentration of Si NP was processed in P3HT:PCBM:Si NP. The P3HT:PCBM:Si NP blend film was spin-coated on ITO glass substrate with 1500 rpm spin speed in a glove box. The P3HT:PCBM:Si NP blend film was then annealed at 120°C for 10 min to reduce contact resistance of electrodes. Finally, a 120-nm-thick Ca/Al electrode was deposited onto the P3HT:PCBM:Si NP blend film through a shadow mask by thermal evaporation. The devices were sealed by a glass slide coated with UV glue after UV light irradiation. The device area was about 0.04 cm².

### 3. Results and Discussion

Figure 1 shows the device structure of the produced OPVs, in which P3HT:PCBM:Si NP is the photoactive layer of the device. Calcium was added to the metal electrodes to improve the fill factor (FF) and the open-circuit voltage ($V_{oc}$) [11]. The organic layer of anhydrous molecular residues must be controlled because of calcium oxidizes if it is exposed to oxygen and moisture [12]. The spherical morphology of Si NP was clearly observed, as evidenced from TEM images in Figure 2. It possesses a uniform dispersion with average diameter about 80–100 nm.

A previous study found that the crystallization, interchain interaction, and phase separation of photoactive layers depend on the composite mixture and its doping concentration of nanomaterials. Similar results were obtained for P3HT:PCBM:nanodiamond layers with various nanodiamond concentrations [5]. Phase segregation increases with increasing contact area between aggregated particles. Therefore, doping Si nanoparticles may cause phase separation with high roughness for the OPVs. The Si NP plays an active role in exciton dissociation due to its greater surface-area-to-volume ratio and wider band gap [13]. Furthermore, short-circuit current density ($J_{sc}$) increases with concentration of Si NP. However, the current could be limited by a bottleneck in the hole transport material, P3HT, or the efficiency of exciton dissociation could decrease rapidly when the concentration of Si NP reaches a certain limit.

The photovoltaic characteristics, namely, $V_{oc}$, $J_{sc}$, fill factor (FF), and PCE, for OPVs with different concentration of doping Si NP, are given in Table 1. Figure 3 shows the current-voltage ($I$-$V$) characteristics of OPVs measured under an illumination intensity of 100 Mw cm⁻². The $J_{sc}$ and PCE in OPVs rise with Si NP doping concentration till 0.35 wt%. The 0.35 wt% Si NP doping into the photoactive layer results in an increment in $J_{sc}$ from 8.38 to 9.48 mA cm⁻². The PCE of the OPVs grows from 3.01 to 3.38%. The Si NP doping increases the donor/acceptor interface area for charge separation and shortens the electron transfer path in P3HT:PCBM, which improves the $J_{sc}$ and PCE. However, the PCE decreases when...
Figure 3: The current-voltage (I-V) characteristics of for P3HT:PCBM:SiNP OPVs with various Si NP concentration.

Figure 4: The EQE spectra for P3HT:PCBM:SiNP OPVs with various Si NP concentration.

the concentration of Si NP exceeds 0.35 wt%, probably due to rising leakage current [14].

The EQE spectra for OPVs with different concentration of doping Si NP are shown in Figure 4. Although all EQE spectra are similar in shape, the value of EQE spectra for the OPVs containing 0.35 wt% Si NP is the highest among those of all OPVs. For example, the EQE maximum for the OPVs containing 0.35 wt% Si NP is 44.5% at 500 nm whereas that containing 0.7 wt% Si NP is 35.4% at the same wavelength. The difference is due to an increased rate of electron collection in the OPVs. No obvious change in optical absorption spectra was observed when the active layer was blended with P3HT:PCBM:Si NP. However, the peak wavelengths at approximately 340 nm may attribute to the PCBM band and those at approximately 400–650 nm attribute to the pristine P3HT band in the absorption spectra [15].

4. Conclusion

The OPVs with P3HT:PCBM:Si NP as the photoactive layer have been produced. The Si NP is well dispersed into the P3HT:PCBM polymer matrix. Doping Si NP increases the $J_{sc}$ in OPVs, thus increasing PCE via faster electron collection rate. The highest measured PCE is 3.38%, corresponding to OPVs containing 0.35 wt% Si NP among those of all OPVs. The Si NP can provide extra exciton separation and electron pathways in OPVs, which increases the $J_{sc}$ and PCE.

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References


